	Application No.	Applicant(s)	
	10/812,003	KU ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Cheung Lee	2812	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	ears on the cover sheet w (OR REMAINS) CLOSED or other appropriate comn IGHTS. This application is	in this application. If not included nunication will be mailed in due course. <b>TH</b>	
1. A This communication is responsive to the petition filed on 1.	<u>/3/07</u> .		
2. The allowed claim(s) is/are 3-24 and 26-41.			
Acknowledgment is made of a claim for foreign priority up a) ☐ All b) ☐ Some* c) ☐ None of the:      Certified copies of the priority documents have	e been received.		
2. Certified copies of the priority documents have			
3. Copies of the certified copies of the priority do	cuments nave been receiv	ed in this national stage application from th	
International Bureau (PCT Rule 17.2(a)).			•
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		le a reply complying with the requirements	
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) ☐ including changes required by the Notice of Draftspers		ew ( PTO-948) attached	
1) hereto or 2) to Paper No./Mail Date			
(b) including changes required by the attached Examiner Paper No./Mail Date	's Amendment / Comment	or in the Office action of	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the state of the stat	i.84(c)) should be written on the header according to 37 (	the drawings in the front (not the back) of FR 1.121(d).	
<ol> <li>DEPOSIT OF and/or INFORMATION about the depo- attached Examiner's comment regarding REQUIREMENT</li> </ol>	osit of BIOLOGICAL MA- FOR THE DEPOSIT OF B	FERIAL must be submitted. Note the IOLOGICAL MATERIAL.	
Attachment(s)	5 Matica of	Informal Detect Application	
1. Notice of References Cited (PTO-892)		Informal Patent Application	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)		Summary (PTO-413), b./Mail Date	
3. Information Disclosure Statements (PTO/SB/08),	7. 🛛 Examiner	s Amendment/Comment	
Paper No./Mail Date  4.  Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner	s Statement of Reasons for Allowance	
	9. 🔲 Other		
•	•	Black blaket	
	SU	MICHAEL LEBENTRITT PERVISORY PATENT EXAMINER	

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#### **DETAILED ACTION**

## Notice to Applicant

 Applicants' revised Oath/Declaration filed on January 3, 2007 has been entered and made of record.

#### Examiner's Amendment

- 2. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- 3. Authorization for this examiner's amendment was given in a telephone interview with Mr. Gregory Brummett on September 26, 2006.
- 4. The application has been amended as follows:
  - Cancellation of claim 2.
  - In claim 3, line 1, replace "Original" with --Currently Amended--.
  - In claim 3, line 2, replace "claim 2" with --claim 41--.
  - In claim 6, line 2, replace "claim 2" with --claim 41--.
  - In claim 8, line 2, replace "claim 2" with --claim 41--.
  - In claim 9, line 2, replace "claim 2" with --claim 41--.
  - In claim 41, replace "(not Entered)" with --(Previously Presented) A
    method of forming a semiconductor device comprising, in order:
    implanting a dopant into a substrate to form a source/drain region;

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forming a silicide blocking layer on the substrate;

annealing the substrate to activate a portion of the dopant, the annealing being conducted at an anneal temperature T<sub>a</sub>;

exposing silicon surfaces on the substrate;

forming silicide layers on the exposed silicon surfaces by depositing a nickel alloy layer on the exposed silicon surfaces, the nickel alloy including nickel and an alloying metal; and

reacting the nickel alloy layer with the exposed silicon surface to form a nickel silicide layer having an upper layer and a lower layer, wherein the alloying metal is preferentially segregated in the upper layer, and further wherein the silicide layers are formed at a silidation temperature  $T_s$ , wherein  $T_s < T_{a^{--}}$ .

# Reason for Allowance

5. Claims 3-24 and 26-41 are allowed.

The reasons of allowance were given in the Office Action mailed on April 20, 2006.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Cheung Lee whose telephone number is 571-272-5977. The examiner can normally be reached on Monday through Friday from 8:30AM to 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Cheung Lee

January 29, 2007

MICHAEL LEBENTRITT SUPERVISORY PATENT EXAMINER

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